POLISHING COMPOSITION AND METHOD

Abstract

The polishing slurry includes by weight percent, 0.1 to 50 metal oxy-acid accelerator, 0.5 to 50 cerium oxide abrasive particles and balance water. The metal oxy-acid accelerator is formed with a metal selected from the group consisting of chromium, lanthanum and rare earth metals 59 to 71, manganese, molybdenum, niobium, osmium, rhenium, ruthenium, titanium, tungsten, vanadium, yttrium and zirconium.

This Sheet Has Been Replaced

